IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant

Ted A. Loxley

Serial No.

09/490,162

Filed

January 22, 2000

For: PROCESS AND APPARATUS FOR CLEANING SILICON WAFERS

Examiner

V. Simkovic

Group Art Unit

2812

Box Non-Fee Amendment Assistant Commissioner for Patents Washington, D.C. 20231

AMENDMENT

Sir:

In response to the Office action of May 23, 2001, please amend the above-identified application as follows:

Cancel claim 27.

Add the following new claim:

of 10 or more silicon wafers is supported in a vessel or wafer carrier during the cleaning operations, the front face of each wafer being charged to a limited negative voltage, such as 2 to 60 volts, insufficient to harm the delicate microcircuits formed on that face and having a field intensity of at least 0.02 volts/mm sufficient to cause efficient removal of harmful sub 0.05-micro particles. At





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